

CLAIM AMENDMENTS

1. (Previously Amended) An optical modulator comprising:
a semi-insulating semiconductor substrate with a principal plane including a partially exposed surface;
an optical waveguide ridge which is disposed on said semiconductor substrate and which includes a first cladding layer of a first conductivity type, an optical-absorption layer, and a second cladding layer of a second conductivity type, said optical waveguide ridge further having a side with a flat portion extending uniformly from a top of the ridge to said semiconductor substrate, the flat portion being in contact with the exposed surface of said semiconductor substrate;
a dielectric film which covers said optical waveguide ridge and said semiconductor substrate and which has a first opening at the top of said optical waveguide ridge and a second opening in a region of said semiconductor substrate other than the exposed surface;
B/ a first electrode disposed on said dielectric film and mounted through the first opening on the top of said optical waveguide ridge, said first electrode further extending on the flat portion of said optical waveguide ridge in contact with a surface of said dielectric film, said first electrode further having one end on said semiconductor substrate at the exposed surface; and
a second electrode disposed on said semiconductor substrate and connected to the first cladding layer through the second opening in said dielectric film.
2. (Previously Amended) The optical modulator according to claim 1, wherein said semiconductor substrate has exposed surfaces on both sides of said optical waveguide ridge, wherein said optical waveguide ridge has the flat portion on both sides and wherein said first electrode extends over both sides of said optical waveguide ridge, two ends of said first electrode being disposed respectively on the exposed surface of said semiconductor substrate.
3. (Previously Amended) The optical modulator according to claim 1, wherein the first cladding layer has an extension that extends onto a region of said semiconductor

substrate located outside said optical waveguide ridge and excluding the region where said first electrode is disposed.

4. (Previously Amended) The optical modulator according to claim 2, wherein the first cladding layer has an extension that extends onto a region of said semiconductor substrate located outside said optical waveguide ridge and excluding the region where said first electrode is disposed.

5. (Previously Amended) The optical modulator according to claim 3, wherein said second electrode is disposed through said second opening on the extension of the first cladding layer.

6. (Previously Amended) The optical modulator according to claim 4, wherein said second electrode is disposed through said second opening on the extension of the first cladding layer.

7. (Previously Amended) The optical modulator according to claim 1, further comprising a dielectric layer located between said dielectric film and said first electrode and at a base of said optical waveguide ridge, including a region where the flat portion of the ridge is in contact with the exposed surface of said semiconductor substrate.

8. (Previously Amended) The optical modulator according to claim 2, further comprising a dielectric layer located between said dielectric film and said first electrode and at a base of said optical waveguide ridge, including a region where the flat portion of the ridge is in contact with the exposed surface of said semiconductor substrate.

9. (Previously Amended) The optical modulator according to claim 3, further comprising a dielectric layer located between said dielectric film and said first electrode and at a base of said optical waveguide ridge, including a region where the flat portion of the ridge is in contact with the exposed surface of said semiconductor substrate.

10. (Previously Amended) The optical modulator according to claim 4, further comprising a dielectric layer located between said dielectric film and said first electrode and at a base of said optical waveguide ridge, including a region where the flat portion of the ridge is in contact with the exposed surface of said semiconductor substrate.

11. (Previously Amended) The optical modulator according to claim 1, further comprising a conductive layer of said first conductivity type disposed over a part of said semiconductor substrate including a region under said optical waveguide ridge and excluding the region where said first electrode is located, said second electrode being disposed on said semiconductor layer through the second opening in said dielectric film.

12. (Previously Amended) An optical modulator according to claim 1, further comprising a high-resistance semiconductor layer located between one side of said optical waveguide ridge and said dielectric film, said high-resistance semiconductor layer being thinner than said optical waveguide ridge.

B / 13. (Previously Amended) An optical modulator according to claim 2, further comprising a high-resistance semiconductor layer located between one side of said optical waveguide ridge and said dielectric film, said high-resistance semiconductor layer being thinner than said optical waveguide ridge.

14. (Previously Amended) An optical modulator according to claim 3, further comprising a high-resistance semiconductor layer located between one side of said optical waveguide ridge and said dielectric film, said high-resistance semiconductor layer being thinner than said optical waveguide ridge.

15. (Previously Amended) An optical modulator according to claim 4, further comprising a high-resistance semiconductor layer located between one side of said optical waveguide ridge and said dielectric film, said high-resistance semiconductor layer being thinner than said optical waveguide ridge.

16. (Previously Amended) A photonic semiconductor device comprising:
an optical modulator having:

a semi-insulating semiconductor substrate with a principal plane including a partially exposed surface,

an optical waveguide ridge which is disposed on said semiconductor substrate and which includes a first cladding layer of a first conductivity type, an optical-absorption layer, and a second cladding layer of a second conductivity type, said optical waveguide ridge further having a side with a flat portion extending uniformly from a top of the ridge to said semiconductor substrate, the flat portion being in contact with the exposed surface of said semiconductor substrate,

a dielectric film which covers said optical waveguide ridge and said semiconductor substrate and which has a first opening at the top of said optical waveguide ridge and a second opening in a region of said semiconductor substrate other than the exposed surface,

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a first electrode disposed on said dielectric film and mounted through the first opening on the top of said optical waveguide ridge, said first electrode further extending on the flat portion of said optical waveguide ridge in contact with a surface of said dielectric film, said first electrode further having one end on said semiconductor substrate at the exposed surface, and

a second electrode disposed on said semiconductor substrate and connected to the first cladding layer through the second opening in said dielectric film; and

a semiconductor laser device aligned in optical axis with the optical absorption layer of said optical modulator.

17. (Previously Amended) The photonic semiconductor device according to claim 16, wherein said semiconductor laser device is a ridge type device having an optical waveguide ridge disposed on a semi-insulating semiconductor substrate, said semiconductor laser device and said optical modulator being mounted on said substrate.

18. (Previously Amended) An optical modulator fabricating method including:
forming a first cladding layer of a first conductivity type, an optical absorption layer,
and a second cladding layer of a second conductivity type on a semi-insulating
semiconductor substrate;

forming by photolithography and etching an exposed surface of the semiconductor
substrate as well as an optical waveguide ridge which has a side with a flat portion extending
uniformly from a top of the ridge to the semiconductor substrate, the flat portion being in
contact with the exposed surface of the semiconductor substrate;

forming a dielectric film over the semiconductor substrate and first and second
openings through the dielectric film, the first opening being made at the top of the optical
waveguide ridge, the second opening being made in a region of the semiconductor substrate
excluding the exposed surface;

forming a first electrode through the first opening on the top of the optical waveguide
ridge, extending on the flat portion of the optical waveguide ridge and in contact with a
surface of the dielectric film, the first electrode further having one end on the semiconductor
substrate at the exposed surface; and

forming a second electrode connected to the first cladding layer through the second
opening in the dielectric film.

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19. (Previously Amended) The optical modulator fabricating method according to
claim 18, wherein forming the exposed surface of the semiconductor substrate includes
forming exposed surfaces of the semiconductor substrate on both sides of said optical
waveguide ridge, as well as the flat portion on both sides of the optical waveguide ridge, and
wherein forming a first electrode includes forming the first electrode to extend over both
sides of the optical waveguide ridge, the first electrode having two ends on the exposed
surfaces of the semiconductor substrate.

20. (Previously Amended) The optical modulator fabricating method according to
claim 18, wherein forming of the first cladding layer is preceded by forming a conductive
layer of the first conductivity type over part of the semi-insulating semiconductor substrate,
forming the exposed surface of the semiconductor substrate includes forming an exposed

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surface of the conductive layer while forming the exposed surface of the semiconductor substrate, and forming the second electrode includes forming the second electrode on the conductive layer through the second opening.
